

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	722	(sens\$3 or detect\$3 or measur\$3 or calculat\$3 or monitor\$3) near3 oxygen near2 density	US-PGPUB; USPAT; DERWENT	OR	ON	2005/03/31 08:04
S2	218	(sens\$3 or detect\$3 or measur\$3 or calculat\$3 or monitor\$3) near3 moisture near2 density	US-PGPUB; USPAT; DERWENT	OR	ON	2005/03/31 08:04
S3	2	(control\$4 or regulat\$3) near4 (light or laser) same S1 same S2	US-PGPUB; USPAT; DERWENT	OR	ON	2005/03/31 08:08
S4	3	S1 and S2	US-PGPUB; USPAT; DERWENT	OR	ON	2005/03/31 08:02
S5	1227	(sens\$3 or detect\$3 or measur\$3 or calculat\$3 or monitor\$3) near5 oxygen near2 density	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/03/31 08:14
S6	374	(sens\$3 or detect\$3 or measur\$3 or calculat\$3 or monitor\$3) near5 moisture near2 density	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/03/31 08:14
S7	5	S5 and S6	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/03/31 08:05
S8	4	(control\$4 or regulat\$3) near4 (light or laser or exposure) same (S5 or S6)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/03/31 08:16
S9	16214	(sens\$3 or detect\$3 or measur\$3 or calculat\$3 or monitor\$3) near5 oxygen near2 concentration	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/03/31 08:14
S10	28535	(sens\$3 or detect\$3 or measur\$3 or calculat\$3 or monitor\$3) near5 (moisture near2 (density or concentration) or moisture)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/03/31 08:15
S11	284	(S5 or S9) and S10	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/03/31 08:15
S12	223	(control\$4 or regulat\$3) near4 (light or laser or exposure) same (S10 or S9)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/03/31 08:17
S13	0	(control\$4 or regulat\$3) near4 (light or laser or exposure) same S9 same S10	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/03/31 08:18

S14	52	S12 and ((mask or reticle) or (wafer or substrate) or lithograph\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/03/31 08:19
S15	21307	(sens\$3 or detet\$3 or measur\$4 or calculat\$3) near4 (amount or quantity) near4 (light or radiation or irradiation)	US-PGPUB; USPAT; DERWENT	OR	ON	2005/04/06 10:05
S16	1232404	(impurit\$3 or light adj absorbing or oxygen or moisture)	US-PGPUB; USPAT; DERWENT	OR	ON	2005/04/06 09:53
S17	561	S15 same S16	US-PGPUB; USPAT; DERWENT	OR	ON	2005/04/06 09:55
S18	220	S17 and (lithograph\$3 or microlithograph\$3 or photolithograph\$3 or (reticle or mask) or (wafer or substrate))	US-PGPUB; USPAT; DERWENT	OR	ON	2005/04/06 10:06
S19	42	S18 and moisture and oxygen	US-PGPUB; USPAT; DERWENT	OR	ON	2005/04/06 09:58
S20	2	S18 and moisture same (control\$4 or regulat\$3) near4 (light or radiation or irradiation) and oxygen same (control\$4 or regulat\$3) near4 (light or radiation or irradiation)	US-PGPUB; USPAT; DERWENT	OR	ON	2005/04/06 10:07
S21	8	S18 and moisture and oxygen and (control\$4 or regulat\$3) near4 (light or radiation or irradiation)	US-PGPUB; USPAT; DERWENT	OR	ON	2005/04/06 10:02
S22	12	S17 and moisture and oxygen and (control\$4 or regulat\$3) near4 (light or radiation or irradiation)	US-PGPUB; USPAT; DERWENT	OR	ON	2005/04/06 10:02
S23	7443	S15 and (lithograph\$3 or microlithograph\$3 or photolithograph\$3 or (reticle or mask) or (wafer or substrate))	US-PGPUB; USPAT; DERWENT	OR	ON	2005/04/06 10:06
S24	3	S23 and moisture same (control\$4 or regulat\$3) near4 (light or radiation or irradiation) and oxygen same (control\$4 or regulat\$3) near4 (light or radiation or irradiation)	US-PGPUB; USPAT; DERWENT	OR	ON	2005/04/06 10:07